

Contents

Zusammenfassung	i
Abstract	iii
Danksagung	v
1. Introduction	1
2. Theory and fundamental concepts	3
2.1. Wave optics and optical waveguiding	3
2.1.1. Optical waveguide modes	4
2.2. Semiconductor light emission and amplification	6
2.3. Refractive index variation	7
2.3.1. Photoelastic effect	7
2.3.2. Thermo-optical effect	9
2.4. Characteristic beam parameters	10
3. Theoretical simulation methods	13
3.1. Electrical model	14
3.2. Thermal model	16
3.3. Mechano-optical influence	18
4. Laboratory setup	21
4.1. Assembly	22
4.2. Passive device	22
4.3. Active device	23
4.4. Transient measurement	23
4.5. Measurement devices	23
5. Thermal waveguiding in passive devices	25
5.1. Epitaxial structure design	26
5.1.1. Thermal distribution	29
5.1.2. Metallization	31
5.2. Straight heater stripes	32
5.2.1. Layout	32
5.2.2. Influence of mechanical stress	33
5.2.3. Electrical simulation and characterization	35
5.2.4. Optical simulation and characterization	37

Contents

5.3. Curved heater stripe	46
5.3.1. Layout	46
5.3.2. Simulation and characterization	47
5.4. Summary	53
5.5. Conclusion	54
6. Thermal waveguiding in active devices	57
6.1. Active vertical structure and heating element	57
6.1.1. Propagation losses in unpumped areas	58
6.2. Beam steering	61
6.2.1. Layout and Concept	61
6.2.2. Simulation and characterization	62
6.3. Astigmatism control	75
6.3.1. Tapered edge-emitting devices and astigmatism	76
6.3.2. Layout	80
6.3.3. Measurement and simulation	83
6.4. Time dependent behavior	94
6.5. Summary	97
6.6. Conclusion	99
7. Outlook	101
Bibliography	105
A. Appendix	113
A.1. Optical imaging	113
A.2. Beam quality measurement	114
A.3. Simulation parameters	115
A.4. Laser sources	119
A.5. Straight heater stripes width variation	120